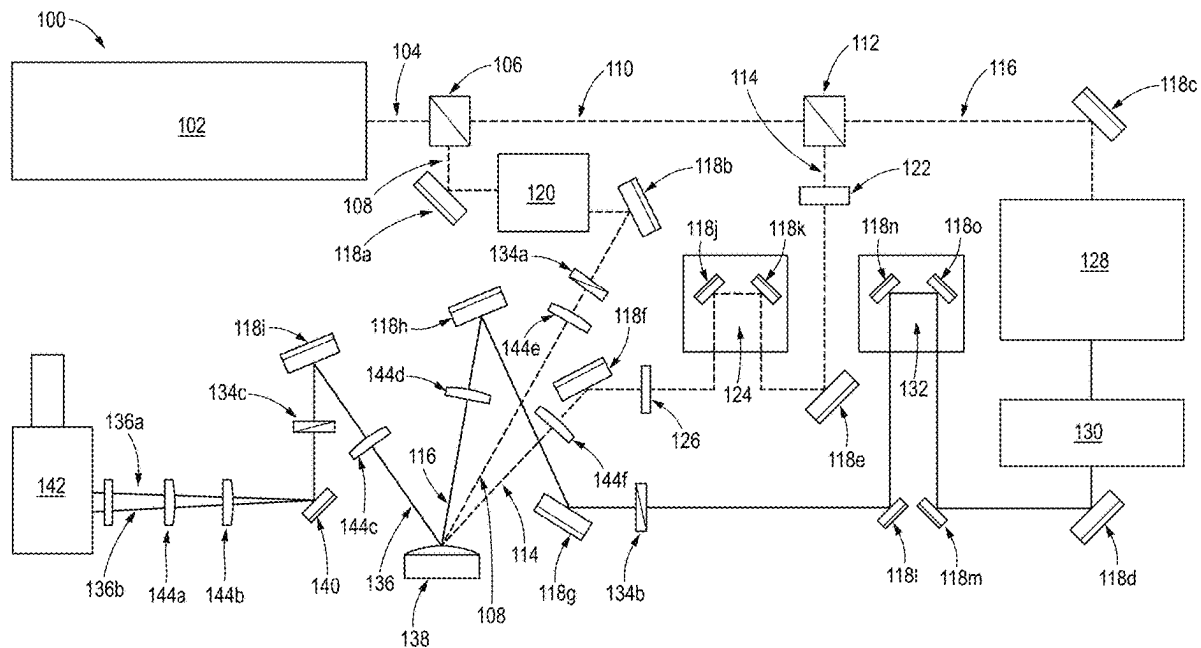




US 20250258420A1

(19) **United States**(12) **Patent Application Publication**
CHEN et al.(10) **Pub. No.: US 2025/0258420 A1**(43) **Pub. Date: Aug. 14, 2025**(54) **TWO-DIMENSIONAL ELECTRONIC
SUM-FREQUENCY GENERATION
APPARATUS AND METHODS**(52) **U.S. Cl.**CPC *G02F 1/3534* (2013.01); *G02F 1/392*
(2021.01); *H01S 3/1625* (2013.01); *H01S*
3/1636 (2013.01); *G02F 2203/11* (2013.01)(71) Applicants: **Honda Motor Co., Ltd.**, Tokyo (JP);
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HUANG-FU, Logan, UT (US)(21) Appl. No.: **18/439,513**(22) Filed: **Feb. 12, 2024****Publication Classification**(51) **Int. Cl.**
G02F 1/35 (2006.01)
G02F 1/39 (2006.01)
H01S 3/16 (2006.01)(57) **ABSTRACT**

Aspects of the present disclosure generally relate to two-dimensional electronic apparatuses and methods of use. A two-dimensional electronic sum frequency generation (2D-ESFG) apparatus includes an amplifier including a laser source. A broadband optical parametric amplifier (BOPA) is optically coupled to the amplifier. The BOPA includes a two-stage amplifier. An etalon is optically coupled to the amplifier. The etalon includes two or more partially reflective substrate optical flats. A noncollinear optical parametric amplifier (NOPA) is optically coupled to the amplifier. A dispersive filter pulse shaper is optically coupled to the NOPA. A synchronizer including a galvanometer mirror is optically coupled to the BOPA, the etalon, and the dispersive filter pulse shaper. A detector is optically coupled to the synchronizer.



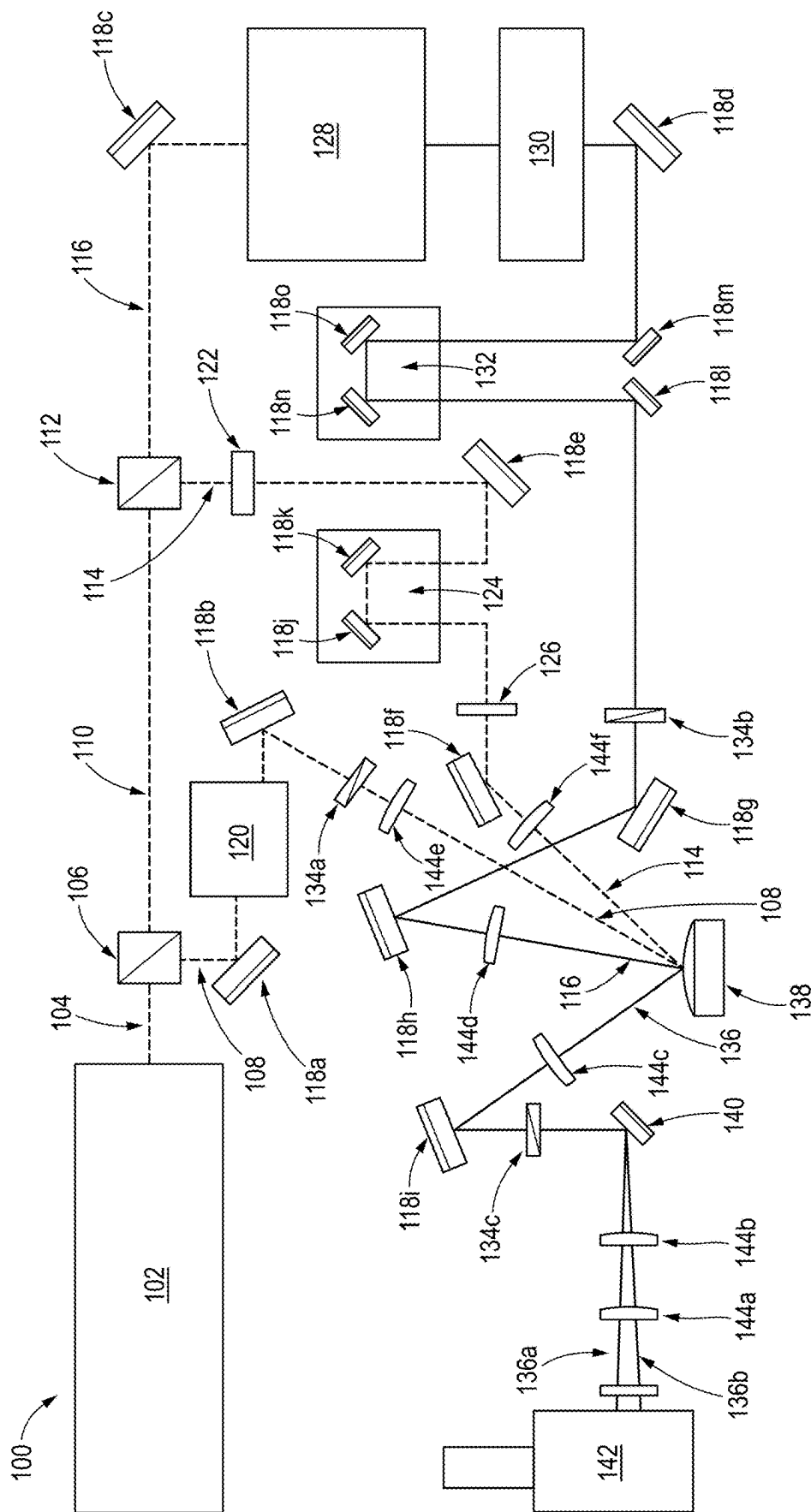


FIG. 1

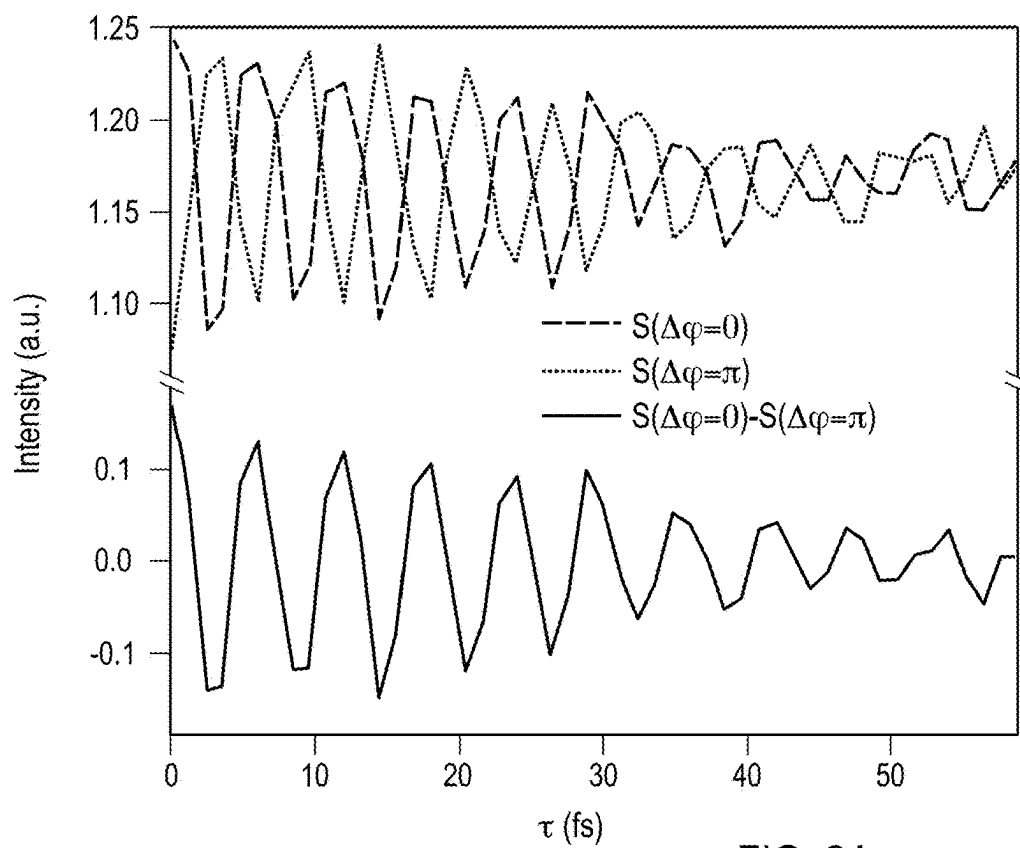


FIG. 2A

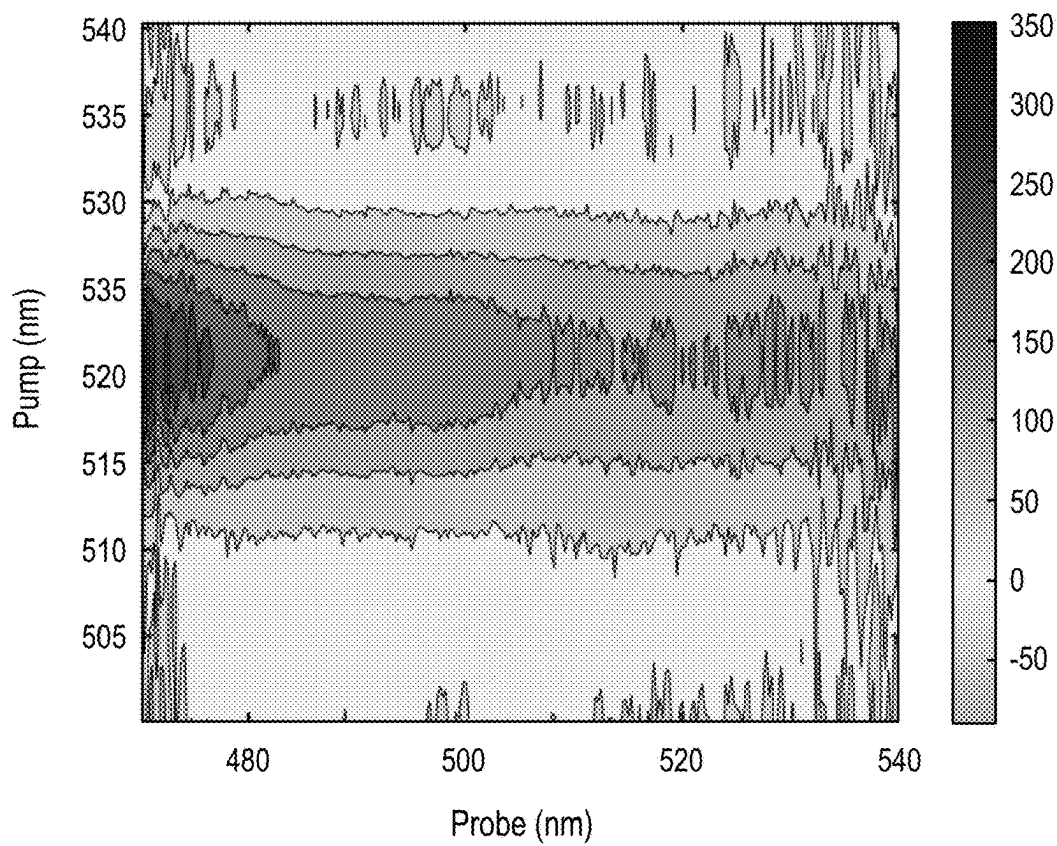


FIG. 2B

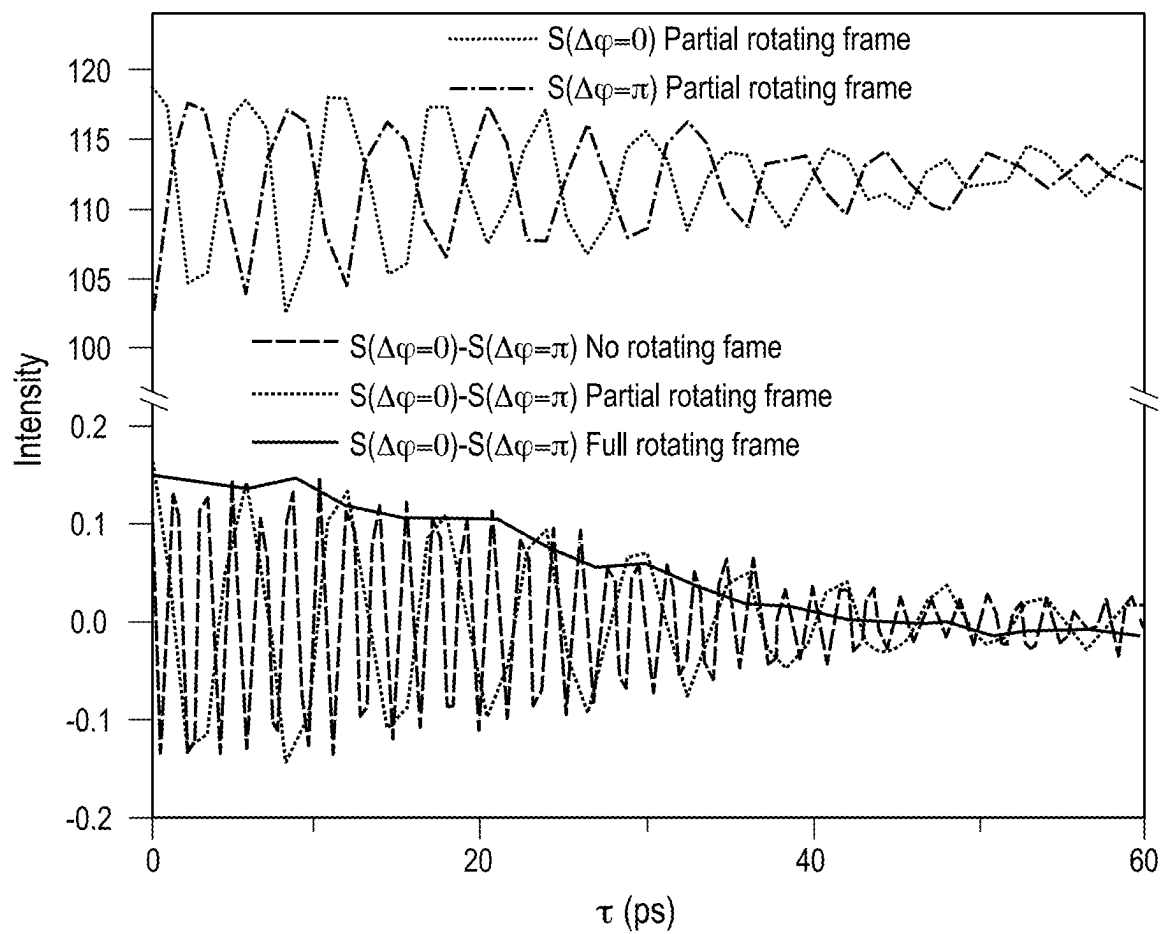
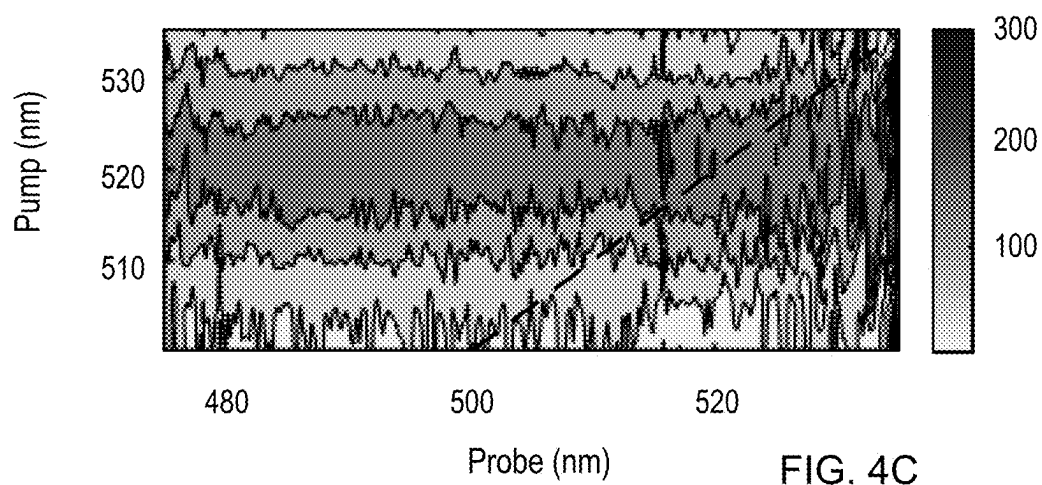
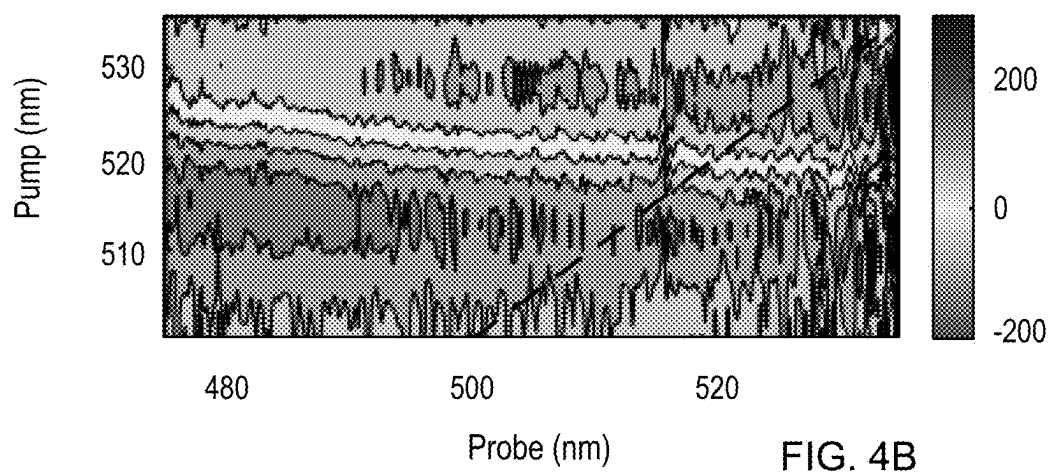
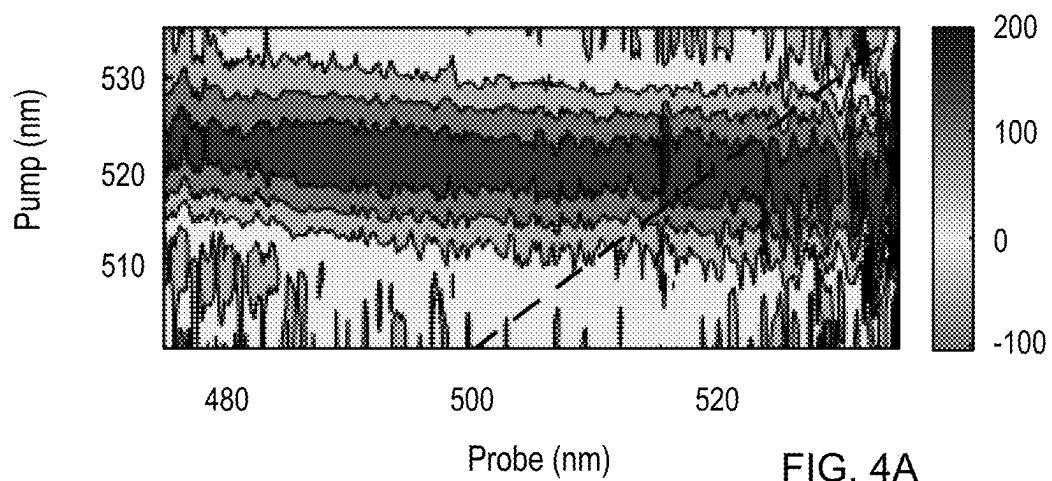
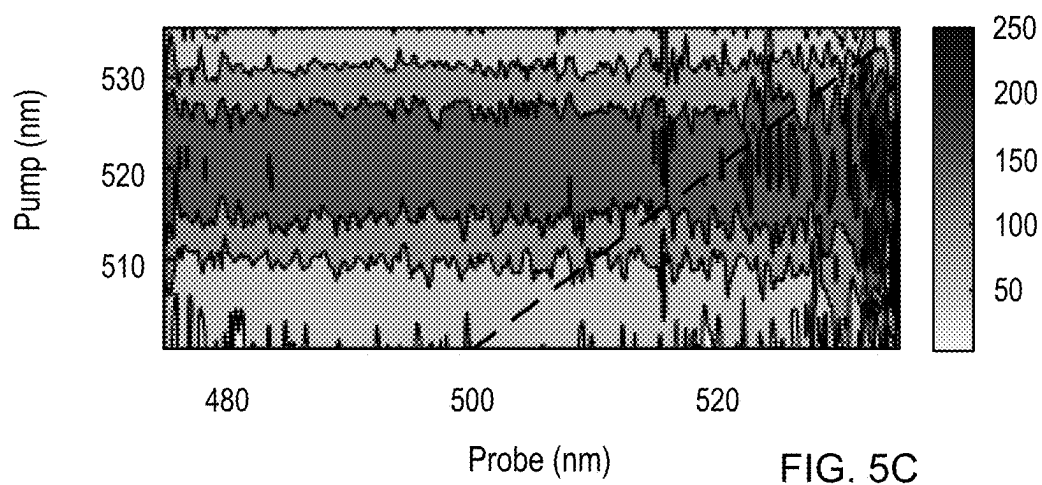
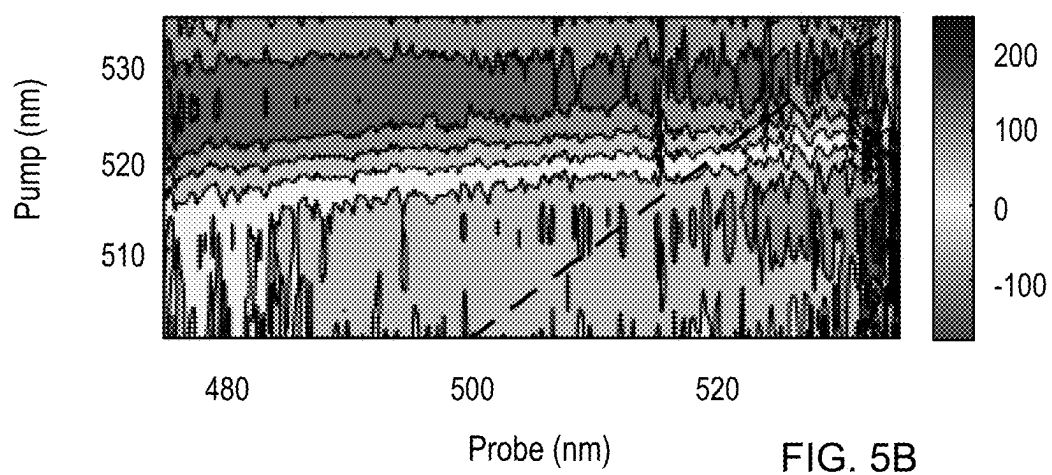
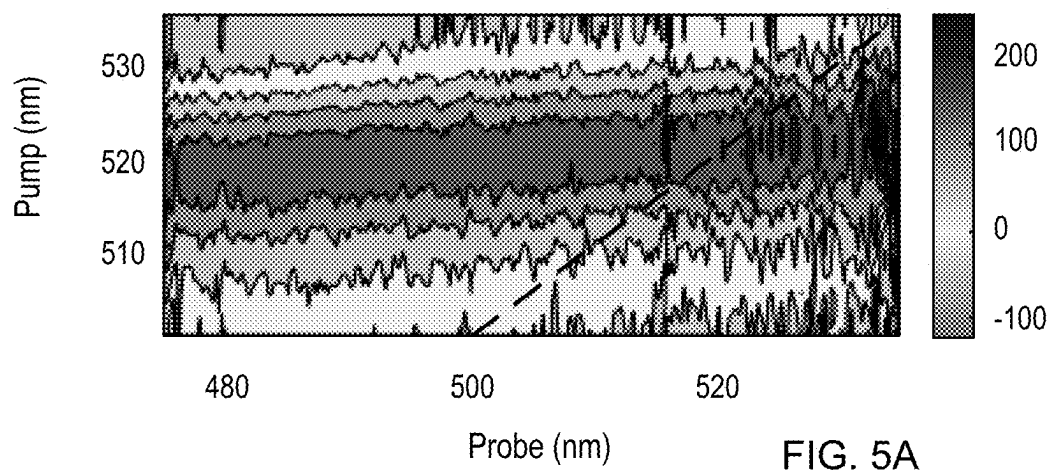
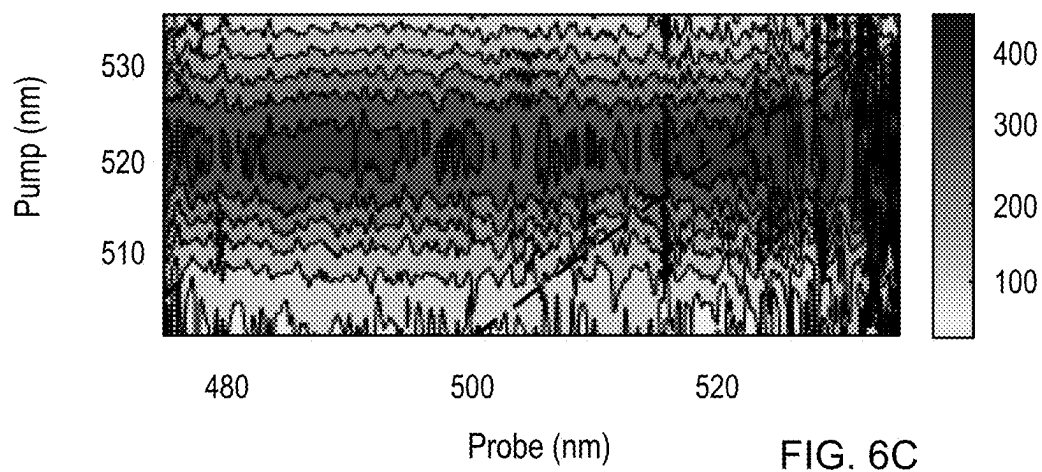
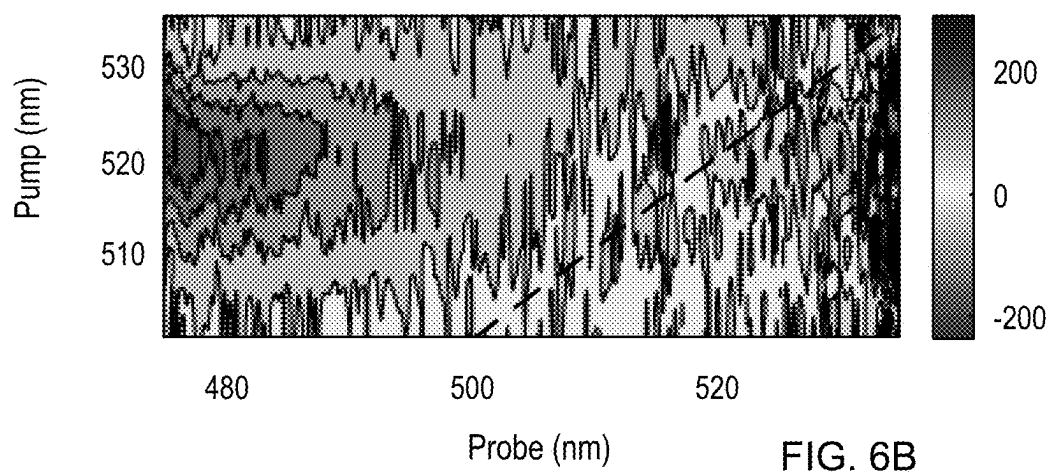
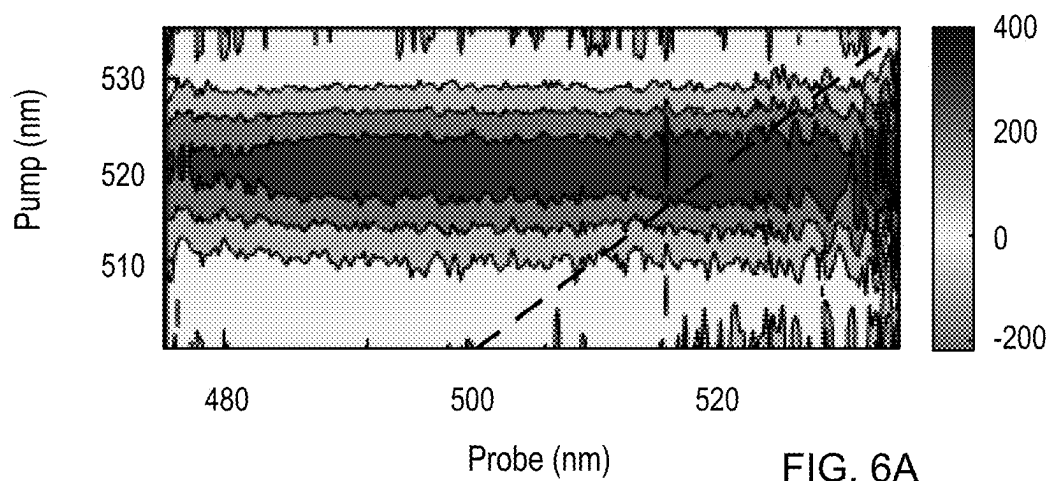


FIG. 3







TWO-DIMENSIONAL ELECTRONIC SUM-FREQUENCY GENERATION APPARATUS AND METHODS

GOVERNMENT RIGHTS

[0001] This invention was made with government support under Grant Number 2045084 awarded by the National Science Foundation. The government has certain rights in the invention.

FIELD

[0002] Aspects of the present disclosure generally relate to two-dimensional electronic apparatus and methods of use.

BACKGROUND

[0003] Ultrafast multidimensional spectroscopy can be utilized to investigate chemical and physical processes of molecules, determine energy transfer and electronic coupling in photochemistry systems, and identify ultrafast nonequilibrium behaviors of biological systems. Among the various techniques, two-dimensional electronic spectroscopy (2D-ES) has become the general technique for assessing energy transfer and electronic interactions among excitons and distinct electronic states in diverse materials, e.g., molecules, nanomaterials, semiconductors, and photosynthetic complexes. 2D-ES spreads the electronic spectrum into a second dimension, enabling the correlation of coupled electronic modes through cross peaks, and providing added dynamic information through 2D line shapes. Unfortunately, 2D-ES lacks specificity when examining electronic and energy transfer dynamics at surfaces and interfaces. Conventional techniques to improve 2D-ES include implementing a second-order nonlinear optical spectroscopy technique, e.g., vibrational and electronic sum frequency generation (2D-VSFG and 2D-ESFG) technique. However, both 2D-VSFG and 2D-ESFG lack multidimensional capabilities and require a broadband laser source with high pulse energy and low temporal chirp to generate ESFG signal.

[0004] Conventional approaches to overcome these limitations have included generating a short-wave infrared (SWIR) using an optical parametric amplifier to develop a Translating Wedge based Identical pulses eNcoating System (TWINS). However, the time delay between two pump pulses at different wavelengths in the birefringent wedges of a TWINS-based 2D-ESFG is different. Accordingly, the time zero between two pump pulses has to be determined prior to analysis. Additionally, the lack of a time zero between two pump pulses prevents conventional phase control techniques used in 2D-ES and 2D-ESFG to be implemented, limiting the removal of scattering, rapid data collection, and the ability to obtain a background-free spectra.

[0005] There is a need for a new two-dimensional electronic apparatus and methods of use.

SUMMARY

[0006] Aspects of the present disclosure generally relate to a two-dimensional electronic apparatus and methods of use. The 2D-ESFG apparatus described herein can include a visible pulse shaper and a pump-probe geometry capable of controlling pulse shapes, allowing for optimized data acquisition and can separate rephrasing and non-rephrasing signals. By controlling pulse shapes of 2D-ESFG apparatus,

increased control over the delay and phase for the pump pulses can be obtained, and the ability to separate rephrasing and non-rephrasing signals can be achieved. 2D-ESFG apparatus described herein can be implemented on a broader range of interfacial systems and/or surfaces compared to conventional 2D-ESFG spectrometers, allowing the electronic structure and dynamics of interface and surface species in environmental, catalytical, and biological systems to be determined.

[0007] Aspects of the present disclosure can provide two-dimensional electronic sum frequency generation (2D-ESFG) apparatuses. The 2D-ESFG includes an amplifier including a laser source. A broadband optical parametric amplifier (BOPA) is optically coupled to the amplifier. The BOPA includes a two-stage amplifier. An etalon is optically coupled to the amplifier. The etalon includes two or more partially reflective substrate optical flats. A noncollinear optical parametric amplifier (NOPA) is optically coupled to the amplifier. A dispersive filter pulse shaper is optically coupled to the NOPA. A synchronizer including a galvanometer mirror is optically coupled to the BOPA, the etalon, and the dispersive filter pulse shaper. A detector is optically coupled to the synchronizer.

[0008] Aspects of the present disclosure can also provide two-dimensional electronic sum frequency generation (2D-ESFG) apparatuses. The 2D-ESFG includes an amplifier including a laser source adapted to emit a laser light. A noncollinear optical parametric amplifier (NOPA) is adapted to shape the laser light emitted from the amplifier. A dispersive filter pulse shaper is adapted to generate a pulse pump pair from the laser light shaped by the NOPA. A synchronizer including a galvanometer mirror is adapted to reflect the pulse pump pair. A detector is adapted to detect a wavelength of the pulse pump pair.

[0009] Aspects of the present disclosure can also provide methods. The methods can include emitting a light from an amplifier to a first beam splitter. The first beam splitter is configured to produce a first portion of light and a second portion of light. A third portion of light and a fourth portion of light are produced by directing the second portion of light to a second beam splitter. The first portion of light is directed to a broadband optical parametric amplifier (BOPA). The third portion of light is directed to an etalon including two or more partially reflective substrate optical flats. The fourth portion of light is directed to a noncollinear optical parametric amplifier (NOPA). The fourth portion of light exits the NOPA and is directed to a dispersive filter pulse shaper. An ESF light is produced by overlaying the first portion of light exiting the BOPA, the third portion of light exiting the etalon, and the fourth portion of light exiting the dispersive filter pulse shaper on a sample. The ESF light is split using a synchronizer to form a first portion of ESFG light and a second portion of ESFG light. The first portion of ESFG light and the second portion of ESFG light are detected.

BRIEF DESCRIPTION OF THE DRAWINGS

[0010] The patent or application file contains at least one drawing executed in color. Copies of this patent or patent application publication with color drawing(s) will be provided by the Office upon request and payment of the necessary fee.

[0011] So that the manner in which the above recited features of the present disclosure can be understood in detail, a more particular description of the disclosure, briefly sum-

marized above, may be had by reference to aspects, some of which are illustrated in the appended drawings. It is to be noted, however, that the appended drawings illustrate only exemplary aspects and are therefore not to be considered limiting of its scope, for the disclosure may admit to other equally effective aspects.

[0012] FIG. 1 is a schematic view of an example two-dimensional electronic sum-frequency generation spectrometer according to at least one aspect of the present disclosure.

[0013] FIG. 2A shows exemplary signal intensity data collected using a 2D-ESFG spectrometer according to at least one aspect of the present disclosure.

[0014] FIG. 2B shows exemplary data of an absorptive 2D-ESFG spectrum of n-type Gallium phosphide (GaP) according to at least one aspect of the present disclosure.

[0015] FIG. 3 shows exemplary signal intensity data collected using a 2D-ESFG spectrometer having a rotating frame according to at least one aspect of the present disclosure.

[0016] FIG. 4A shows exemplary data of a real part of rephrasing signal of In-type GaP (100) according to at least one aspect of the present disclosure.

[0017] FIG. 4B shows exemplary data of an imaginary part of rephrasing signal of In-type GaP (100) according to at least one aspect of the present disclosure.

[0018] FIG. 4C shows exemplary data of an absorption signal of rephrasing signal of In-type GaP (100) according to at least one aspect of the present disclosure.

[0019] FIG. 5A shows exemplary data of a real part of non-rephrasing signal of In-type GaP (100) according to at least one aspect of the present disclosure.

[0020] FIG. 5B shows exemplary data of an imaginary part of non-rephrasing signal of In-type GaP (100) according to at least one aspect of the present disclosure.

[0021] FIG. 5C shows exemplary data of an absorption signal of non-rephrasing signal of In-type GaP (100) according to at least one aspect of the present disclosure.

[0022] FIG. 6A shows exemplary data of a sum of a real part of the rephrasing and non-rephrasing signals of In-type GaP (100) according to at least one aspect of the present disclosure.

[0023] FIG. 6B shows exemplary data of a sum of an imaginary part of the rephrasing and non-rephrasing signals of In-type GaP (100) according to at least one aspect of the present disclosure.

[0024] FIG. 6C shows exemplary data of a sum of an absorption signal of the rephrasing and non-rephrasing signals of In-type GaP (100) according to at least one aspect of the present disclosure.

DETAILED DESCRIPTION

[0025] Aspects of the present disclosure generally relate to two-dimensional electronic apparatus and methods of use. The present disclosure provides 2D-ESFG apparatus using a dispersive filter pulse shaper and a pump-probe geometry capable of controlling pulse shapes, allowing for optimized data acquisition and can separate rephrasing and non-rephrasing signals. By controlling pulse shapes of 2D-ESFG apparatus, increased control over the delay and phase for the pump pulses of light can be obtained, and the ability to separate rephrasing and non-rephrasing signals can be achieved. In at least one aspect, 2D-ESFG apparatus of the present disclosure can be implemented on a broader range of interfacial systems and/or surfaces compared to conven-

tional 2D-ESFG spectrometers, allowing determination of the electronic structure and dynamics of interface and surface species in environmental, catalytic, and biological systems.

Apparatus

[0026] FIG. 1 shows a schematic view of an example two-dimensional electronic sum-frequency generation apparatus (2D-ESFG) 100. The 2D-ESFG 100 includes an amplifier 102. The amplifier 102 can include an energy source, e.g., a laser source. In an aspect, the laser source can include a titanium (Ti) based laser. For example, the laser source can include a titanium:sapphire (Ti:sapphire) laser or a titanium:alumina (Ti:Al₂O₃) laser. The laser generates a laser light 104, e.g., a light wave having spatial coherence.

[0027] The 2D-ESFG 100 can include a first beam splitter 106 optically coupled to the amplifier. The first beam splitter 106 can include an optical device including one or more prisms that can reflect about 40% to about 60% of a laser light 104 and concurrently transmit about 40% to about 60% of the laser light 104. For example, the first beam splitter 106 can split the laser light 104 into a first portion of light 108 and a second portion of light 110. For example, the first beam splitter 106 can reflect about 50% of the laser light 104 as a first portion of light 108. Concurrently, the first beam splitter 106 can transmit about 50% of the laser light 104 as a second portion of light 110.

[0028] The first beam splitter 106 is optically coupled to a broadband optical parametric amplifier (BOPA) 120 via the first portion of light 108. The BOPA 120 can include a two-stage amplifier suitable for producing a plurality of wavelengths by an optical parametric amplification process. In an aspect, the first portion of light 108 can be directed to the BOPA 120 using one or more mirrors 118a-o, as described herein.

[0029] The 2D-ESFG 100 can include a second beam splitter 112 optically coupled to the first beam splitter 106 via the second portion of light 110. The second beam splitter 112 can include any suitable beam splitter described herein, such as the first beam splitter 106. For example, the second beam splitter 112 can split the second portion of light 110 into a third portion of light 114 and a fourth portion of light 116. For example, the second beam splitter 112 can reflect about 50% of the second portion of light 110 as a third portion of light 114. Concurrently, the first beam splitter 106 can transmit about 50% of the second portion of light 110 as a fourth portion of light 116.

[0030] The second beam splitter 112 is optically coupled to an etalon 122 via the third portion of light 114. An etalon 122 can include two or more partially reflective substrate optical flats that are spaced about 1 μm to about 100 cm apart, e.g., about 1 μm to about 10 μm, about 10 μm to about 100 μm, about 100 μm to about 1 cm, about 1 cm to about 10 cm, or about 10 cm to about 100 cm. In an aspect, the two or more partially reflective substrate optical flats are oriented parallel to one another such that light may reflect in the etalon until it reaches an optical cavity. In an aspect, the third portion of light 114 can be directed through an etalon 122 using one or more mirrors 118a-o, as described herein.

[0031] In an aspect, the 2D-ESFG 100 can include a first stage 124. The first stage 124 can include a motorized stage. The motorized stage can translate one or more mirrors, optical elements, focusing lenses, filters, reflectors, or a combination thereof attached and/or secured to the motor-

ized stage, where the one or more mirrors optical elements, focusing lenses, filters, reflectors, or a combination thereof are optically coupled to the etalon 122 via the third portion of light 114 that exits the etalon 122.

[0032] A narrow-band filter 126 is optically coupled to the etalon 122. In an aspect, the third portion of light 114 can exit the etalon 122 and be directed to the narrow-band filter 126. The narrow-band filter 126 can selectively transmit the third portion of light 114 that is about 0.1 nm to about 10 nm outside of a predetermined wavelength, e.g., about 800 nm. For example, the narrow-band filter 126 can selectively transmit the third portion of light 114 having a wavelength of about 800 nm, where the third portion of light 114 having a wavelength of less than 790 nm or greater than 810 nm may be reflected and/or absorbed by the narrow-band filter 126. As a further example, the narrow-band filter 126 can selectively transmit the third portion of light 114 having a wavelength of about 800 nm, where the third portion of light 114 having a wavelength of less than 799.9 nm or greater than 800.1 nm may be reflected and/or absorbed by the narrow-band filter 126.

[0033] The second beam splitter 112 is optically coupled to a noncollinear optical parametric amplifier (NOPA) 128 via the fourth portion of light 116. The NOPA 128 can include a noncollinear amplifier suitable for producing a plurality of wavelengths by allowing a constant gain up to second order in wavelengths by an optical parametric amplification process, which can provide a wider bandwidth than an optical parametric amplifier. For example, the NOPA 128 can be produce a 1400 nm laser by doubling an 800 μ J, 800 nm, 100 fs, laser using a second harmonic generation crystal. Additionally, and as a further example, a white light seed laser may be produced using 1 to 2 μ J, 800 nm, 100 fs, laser. The 1400 nm laser and the white light seed laser may be overlapped on a Beta barium borate (BBO) crystal at an angle of about 4° to about 6° to generate a broadband laser. In an aspect, the second beam splitter 112 can be optically coupled to the NOPA 128 using one or more mirrors 118a-o, as described herein.

[0034] A dispersive filter pulse shaper 130 is optically coupled to an exit of the NOPA 128. The dispersive filter pulse shaper 130 generates a delayed pulse pair from a single input pulse. For example, the fourth portion of light 116 can be directed to the NOPA 128, where the fourth portion of light 116 may exit the NOPA 128 and be directed to the dispersive filter pulse shaper 130. The dispersive filter pulse shaper 130 can include an acousto-optic dispersive filter pulse shaper, which may produce a delayed pulse pair from a single input pulse using a longitudinal interaction between a polychromatic acoustic wave and a polychromatic optical wave in the bulk of a birefringent crystal. For example, the dispersive filter pulse shaper can include a Dazzler™, by FastLite, Antibes, France.

[0035] In an aspect, the 2D-ESFG 100 can include a second stage 132. The second stage 132 can include a motorized stage. The motorized stage can translate one or more mirrors, optical elements, focusing lenses, filters, reflectors, or a combination thereof attached and/or secured to the motorized stage, where the one or more mirrors optical elements, focusing lenses, filters, reflectors, or a combination thereof are optically coupled to the dispersive filter pulse shaper 130 via the fourth portion of light 116 that exits the dispersive filter pulse shaper 130.

[0036] The 2D-ESFG 100 can include one or more mirrors 118a-o optically coupled to the first portion of light 108, second portion of light 110, third portion of light 114, fourth portion of light 116, and/or an ESFG light 136 (e.g., light aligned into a single incident plane after interacting with the sample 138). The one or more mirrors 118a-o can provide greater than 90% reflectance of the first portion of light 108, third portion of light 114, and/or the fourth portion of light 116, e.g., greater than 90% reflectance, greater than 91% reflectance, greater than 92% reflectance, greater than 93% reflectance, greater than 94% reflectance, greater than 95%, greater than 96%, greater than 97%, greater than 98%, or greater than 99%.

[0037] The 2D-ESFG 100 can include one or more polarizers 134a-c optically coupled to the first portion of light 108, second portion of light 110, third portion of light 114, fourth portion of light 116, and/or an ESFG light 136. In an aspect, the one or more polarizers 134a-c can include a wave plate (not shown). The wave plate can include a half-wave plate and/or a quarter-wave plate. A half-wave plate can shift the polarization direction of linearly polarized light, e.g., p to s or s to p. A quarter-wave plate can shift the polarization direction of linearly polarized light to circularly polarized light.

[0038] A sample 138 can be placed in a holder of the 2D-ESFG 100, where the sample 138 is optically coupled to the BOPA 120, etalon 122, NOPA 128, and the dispersive filter pulse shaper 130 via the first portion of light 108, the third portion of light 114, and the fourth portion of light 116. The sample 138 can include a single crystalline sample, e.g., p-type gallium arsenide (GaAs), n-type Gallium phosphide (GaP) In-type GaP (100). The sample 138 can include an aqueous sample, e.g., organic fluid, aqueous fluid, water, or a combination thereof.

[0039] A synchronizer 140 is optically coupled to the sample 138, via the ESFG light 136. The synchronizer 140 can include a galvanometer mirror. The galvanometer mirror can include a single axis system capable of reflecting light along a first plane or a dual axis system capable of reflecting light along a first plane and/or a second plane. For example, the galvanometer mirror can include a single-axis galvanometer mirror. The galvanometer mirror can include a max beam diameter of about 5 mm to about 10 mm, e.g., about 5 mm to about 6 mm, about 6 mm to about 7 mm, about 7 mm to about 8 mm, about 8 mm to about 9 mm, or about 9 mm to about 10 mm. The galvanometer mirror can include a wavelength range of about 400 nm to about 20 μ m, e.g., about 400 nm to about 1 μ m, about 1 μ m to about 10 μ m, or about 10 μ m to about 20 μ m. The galvanometer mirror can include a repeatability of about 10 microradians (μ rad) to about 20 μ rad, e.g., about 10 μ rad to about 13 μ rad, about 13 μ rad to about 16 μ rad, or about 16 μ rad to about 20 μ rad. The galvanometer mirror can include a linearity of about 98% to about 99.9%, e.g., about 99.9%. The galvanometer mirror can include a damage threshold of about 0.25 J/cm² to about 3 J/cm² using a 10 ns pulse, e.g., about 0.25 J/cm² to about 1.0 J/cm², about 1.0 J/cm² to about 2.0 J/cm², or about 2.0 J/cm² to about 3.0 J/cm². The galvanometer mirror can include a max scan angle of about -12.5° to about 12.5°, e.g., about -12.5° to about -10°, about -10° to about 0°, about 0° to about 10°, or about 10° to about 12.5°. The galvanometer mirror can include a resolution of about 15 μ rad to about 70 μ rad, e.g., about 15 μ rad to about 20 μ rad,

about 20 μ rad to about 40 μ rad, about 40 μ rad to about 60 μ rad, or about 60 μ rad to about 70 μ rad.

[0040] The 2D-ESFG **100** includes a detector **142** optically coupled to the synchronizer **140**, via the ESFG light **136**. The detector **142** can include a charge-coupled detector (CCD). The CCD detector can include an integrated circuit having an array of linked, or coupled, p-doped metal-oxide semiconductor capacitors.

[0041] The 2D-ESFG **100** can include one or more lenses **144a-f** optically coupled to the first portion of light **108**, second portion of light **110**, third portion of light **114**, fourth portion of light **116**, ESFG light **136**, first portion of ESFG light **136a**, or second portion of ESFG light **136b**. While only a few locations are shown in FIG. 1, the one or more lenses **144a-f** can be placed along any suitable location of the 2D-ESFG **100**. The one or more lenses **144a-f** can include a substrate suitable for focusing light into a line and/or a point. In an aspect, the one or more lenses can include a cylindrical lens, a spherical lens, and/or a toric lens. For example, the one or more lenses **144a-f** can include a cylindrical lens.

[0042] The 2D-ESFG **100** can include one or more filters (not shown) optically coupled to the first portion of light **108**, second portion of light **110**, third portion of light **114**, fourth portion of light **116**, ESFG light **136**, first portion of ESFG light **136a**, or second portion of ESFG light **136b**. The one or more filters (not shown) can remove fundamental light and/or other light, e.g., extraneous light from the surroundings, in the 2D-ESFG **100**. As used herein, “fundamental light,” is light that is naturally occurring within the 2D-ESFG **100**. As used herein, “other light,” is extraneous light that can enter the 2D-ESFG. The one or more filters (not shown) can be placed along any suitable location of the 2D-ESFG **100** such that the first portion of light **108**, second portion of light **110**, third portion of light **114**, fourth portion of light **116**, ESFG light **136**, first portion of ESFG light **136a**, or second portion of ESFG light **136b** such that a removal of fundamental light and/or other light, e.g., extraneous light from the surroundings, may be reflected and/or absorbed. For example, the one or more filters can include a 780 nm short-pass filter and/or a 445 nm long-pass filter located along the first portion of ESFG light **136a**. As a further example, the one or more filters can include a 780 nm short-pass filter and/or a 445 nm long-pass filter located along the second portion of ESFG light **136b**.

Methods

[0043] In operation, the amplifier **102** emits the laser light **104** to the first beam splitter **106**. For example, an amplifier **102** including a laser source can emit a laser light **104**, e.g., about 650 nm to about 1100 nm, such as about 650 nm to about 800 nm, about 800 nm to about 1000 nm, or about 1000 nm to about 1100 nm. In an aspect, the amplifier **102** can pulse the laser light **104**. The pulse can provide about 3 millijoules (mJ) to about 5 mJ of energy, e.g., about 3 mJ to about 3.5 mJ, about 3.5 mJ to about 4 mJ, about 4 mJ to about 4.5 mJ, or about 4.5 mJ to about 5 mJ, for a period of about 1 femtoseconds (fs) to about 1000 fs, e.g., about 1 fs to about 100 fs, about 100 fs to about 500 fs, or about 500 fs to about 1000 fs. The frequency of the amplifier **102** can include a repetition rate of about 0.1 kHz to about 2 kHz, e.g., about 0.1 kHz to about 0.5 kHz, about 0.5 kHz to about 1.0 kHz, about 1.0 kHz to about 1.5 kHz, or about 1.5 kHz to about 2.0 kHz.

[0044] In an aspect, the first beam splitter **106** produces a first portion of light **108** and a second portion of light **110** by splitting the laser light **104**. For example, the first beam splitter **106** can produce the first portion of light **108** by reflecting about 50% of the laser light **104** as a first portion of light **108**. Concurrently, the first beam splitter **106** can produce the second portion of light **110** by transmitting about 50% of the light as a second portion of light **110**. In an aspect, the first portion of light **108** can include about 1.0 mJ to about 1.5 mJ of energy, e.g., about 1.0 mJ to about 1.1 mJ, about 1.1 mJ to about 1.2 mJ, about 1.2 mJ to about 1.3 mJ, about 1.3 mJ to about 1.4 mJ, or about 1.4 mJ to about 1.5 mJ.

[0045] A third portion of light **114** and a fourth portion of light **114** are produced by directing the second portion of light **110** from the first beam splitter **106** to the second beam splitter **112**. In an aspect, the third portion of light **114** can include about 1.0 mJ to about 2.0 mJ of energy, e.g., about 1.0 mJ to about 1.1 mJ, about 1.1 mJ to about 1.2 mJ, about 1.2 mJ to about 1.3 mJ, about 1.3 mJ to about 1.4 mJ, about 1.4 mJ to about 1.5 mJ, about 1.5 mJ to about 1.6 mJ, about 1.6 mJ to about 1.7 mJ, about 1.7 mJ to about 1.8 mJ, about 1.8 mJ to about 1.9 mJ, or about 1.9 mJ to about 2.0 mJ. In an aspect, the fourth portion of light **116** can include about 0.5 μ J to about 1.0 μ J of energy, e.g., about 0.5 μ J to about 0.6 μ J, about 0.6 μ J to about 0.7 μ J, about 0.7 μ J to about 0.8 μ J, about 0.8 μ J to about 0.9 μ J, or about 0.9 μ J to about 1.0 μ J.

[0046] The first portion of laser light **104** is directed to the BOPA **120** using the first beam splitter **106** (not shown) or mirror **118a**. In an aspect, the BOPA **120** can produce an ultra-broadband short wave infrared light (SWIR) having a wavelength of about 1200 nm to about 2400 nm, e.g., about 1200 nm to about 1400 nm, about 1400 nm to about 1600 nm, about 1600 nm to about 1800 nm, about 1800 nm to about 2000 nm, about 2000 nm to about 2200 nm, or about 2200 nm to about 2400 nm. The BOPA **120** can provide an SWIR having a pulse energy of about 200 μ J to about 300 μ J, e.g., about 200 μ J to about 220 μ J, about 220 μ J to about 240 μ J, about 240 μ J to about 260 μ J, about 260 μ J to about 280 μ J, or about 280 μ J to about 300 μ J, and a pulse duration of about 100 fs to about 300 fs, e.g., about 100 fs to about 150 fs, about 150 fs to about 200 fs, about 200 fs to about 250 fs, or about 250 fs to about 300 fs, when introducing the first portion of light **108** to the BOPA **120**.

[0047] The third portion of light **114** is directed to the etalon **122** having two or more partially reflective substrate optical flats, as described herein, using a the second beam splitter **112** and/or one or more mirrors (not shown). The optical cavity of the etalon **122** can shape the third portion of light **114** to a wavelength of about 700 nm to about 900 nm, e.g., about 700 nm to about 750 nm, about 750 nm to about 800 nm, about 800 nm to about 850 nm, or about 850 nm to about 900 nm. The etalon **122** can shape the third portion of light **114** to have a pulse energy of about 1.7 mJ to about 1.9 mJ, e.g., about 1.7 mJ to about 1.75 mJ, about 1.75 mJ to about 1.8 mJ, about 1.8 mJ to about 1.85 mJ, or about 1.85 mJ to about 1.9 mJ, and a pulse duration of about 1 picoseconds (ps) to about 1000 ps, e.g., about 1 ps to about 100 ps, about 100 ps to about 500 ps, or about 500 ps to about 1000 ps.

[0048] In an aspect, the third portion of light **114** exiting the etalon may be directed to a narrow-band filter **126**. The narrow-band filter can selectively transmit the third portion

of light **114** that is about 0.1 nm to about 10 nm outside of a predetermined wavelength to the sample **138**. For example, the narrow-band filter **126** can selectively transmit the third portion of light **114** having a wavelength of about 800 nm, where the third portion of light **114** having a wavelength of less than 790 nm or greater than 810 nm may be reflected and/or absorbed by the narrow-band filter **126**. As a further example, the narrow-band filter **126** can selectively transmit the third portion of light **114** having a wavelength of about 800 nm, where the third portion of light **114** having a wavelength of less than 799.9 nm or greater than 800.1 nm may be reflected and/or absorbed by the narrow-band filter **126**.

[0049] In an embodiment, the third portion of light **114** exiting the narrow-band filter **126** can be directed using a first stage **124**. The first stage **124** can translate mirrors **118j** and **118k** to adjust an alignment of the third portion of light **114** contacting the sample **138**. The first stage can include a motorized stage configured to translate a distance of about 0.1 μm to about 100 mm, e.g., about 1 μm to about 10 μm , about 10 μm to about 100 μm , about 100 μm to about 1 mm, or about 1 mm to about 100 mm. In an aspect, the first stage **124** can be programmable. Without wishing to be bound by theory the first stage **124** can control a time delay between the first portion of light **108** and the third portion of light **114**.

[0050] The fourth portion of light **116** is directed to the NOPA **128** using the second beam splitter **112** and/or mirror **118c**. The NOPA **128** can shape the fourth portion of light **116** to a wavelength of about 500 nm to about 540 nm, e.g., about 500 nm to about 510 nm, about 510 nm to about 520 nm, about 520 nm to about 530 nm, or about 530 nm to about 540. The NOPA **128** can shape the fourth portion of light to a pulse energy of about 5 μJ to about 10 μJ , e.g., about 5 μJ to about 6 μJ , about 6 μJ to about 7 μJ , about 7 μJ to about 8 μJ , about 8 μJ to about 9 μJ , or about 9 μJ to about 10 μJ , and a full width at half max of about 15 nm to about 25 nm, e.g., about 15 nm to about 16 nm, about 16 nm to about 17 nm, about 17 nm to about 18 nm, about 18 nm to about 19 nm, about 19 nm to about 20 nm, about 20 nm to about 21 nm, about 21 nm to about 22 nm, about 22 nm to about 23 nm, about 23 nm to about 24 nm, or about 24 nm to about 25 nm.

[0051] The fourth portion of light **116** exits the NOPA **128** and is directed to a dispersive filter pulse shaper **130** using the NOPA **128** and/or one or more mirrors (not shown). In an aspect the dispersive filter pulse shaper **130** generates a pump pulse pair, e.g., a first pulse of light and a second pulse of light. The dispersive filter pulse shaper **130** can allow independent phase and amplitude control over each pulse, as described herein.

[0052] In an aspect, the dispersive filter pulse shaper **130** can allow independent phase and amplitude control over each pulse. By controlling the independent phase and amplitude, a scan of t_1 time delay and phase-cycling control can be obtained. For example, a generated pulse pair can be represented by the form $|E(\omega)|(1+\exp[i(\omega t_1 + \varphi_{12})])$ where $E(\omega)$ is the spectral amplitude of the pulse and $\varphi_{12} = \varphi_1 - \varphi_2$ is the relative carrier wave phase shift. In an aspect, the 2D signal can be isolated from other contributions by using a two-step phase-cycling, where the two-step phase cycling produces a first wave phase shift, $\varphi_{12} = 0$, and a second wave phase shift, $\varphi_{12} = \pi$. In an embodiment, by subtracting the first wave phase shift from the second wave phase shift, or

alternatively the second wave shift from the first wave phase shift, a background correction can be performed, thereby providing a background-free spectra. In an aspect, the 2D signal can be isolated from other contributions by using a four-step phase-cycling, where the four-step phase cycling produces a first wave phase shift, $\varphi_{12} = 0$, a second wave phase shift, $\varphi_{12} = \pi/2$, a third wave phase shift, $\varphi_{12} = \pi$, and a fourth wave phase shift, $(\varphi_{12} = 3/2(\pi))$. In an embodiment, by subtracting the first wave phase shift from the second wave phase shift, or alternatively the third wave shift from the fourth wave phase shift, a background correction can be performed, thereby providing a background-free spectra.

[0053] In an embodiment, the fourth portion of light **116** exiting the dispersive filter pulse shaper **130** can be directed using a second stage **132**. The second stage **132** can translate mirrors **118n** and **118o** to adjust an alignment of the fourth portion of light **116** contacting the sample **138**. The second stage can include a motorized stage configured to translate a distance of about 0.1 μm to about 150 mm, e.g., about 1 μm to about 10 μm , about 10 μm to about 100 μm , about 100 μm to about 1 mm, about 1 mm to about 100 mm, or about 100 mm to about 150 mm. In an aspect, the second stage **132** can be programmable. Without wishing to be bound by theory the second stage **132** can control a time delay, T_w , between the pulse pump pairs of the fourth portion of light **116**, the first portion of light **108**, and the third portion of light **114**.

[0054] The first portion of light **108** exiting the BOPA **120** is overlaid on the sample **138** with the third portion of the light **114** exiting the etalon **122**. The first portion of light **108** and the third portion of light **114** can be aligned and focused on a surface of the sample at a spot size diameter of about 500 μm to about 600 μm , e.g., about 500 μm to about 520 μm , about 520 μm to about 540 μm , about 540 μm to about 560 μm , about 560 μm to about 580 μm , or about 580 μm to about 600 μm , with a lens of about 20 cm focal length at an incident angle of 60° to about 150 μm by a 15 cm focal length lens at an incident angle of 45° . Without being bound by theory, by focusing the third portion of light **108** and the second portion of light **114** can produce an ESFG spectrum covering a wavelength range of about 475 nm to about 550 nm, e.g., about 475 nm to about 500 nm, about 500 nm to about 525 nm, or about 525 nm to about 550 nm.

[0055] Concurrently, the fourth portion of light **116** exiting the dispersive filter pulse shaper **130** is spatially overlaid on the sample **138** to produce the ESFG light **136** that reflects off the sample **138**. In an aspect, the fourth portion of light **116** can be focused on the surface of the sample **138** at a spot size diameter of about 250 μm to about 300 μm , e.g., about 250 μm to about 260 μm , about 260 μm to about 270 μm , about 270 μm to about 280 μm , about 280 μm to about 290 μm , or about 290 μm to about 300 μm , with a lens of about 25 cm focal length at an incident angle of 37° .

[0056] In an aspect, the first portion of laser light **104**, the second portion of light **110**, the third portion of light **114**, the fourth portion of light **116**, and/or the ESFG light **136** can be modified by one or more polarizers **134a-c**. The one or more polarizers **134a-c** can restrict and/or alter parallel and/or perpendicular light with respect to an incident plane of the first portion of laser light **104**, the second portion of light **110**, the third portion of light **114**, the fourth portion of light **116**, and/or the ESFG light **136**. For example, the one or more polarizers can be oriented to be “p” (parallel to the incident plane) or “s” (perpendicular to the incident plane).

As a further example, the one or more polarizers **134a-c** can orient the fourth portion of light **116**, the ESFG light **136**, the third portion of light **114**, and the first portion of light **108** to be p, s, s, and p, respectively. Without being bound by theory, the one or more polarizers **134a-c** can block light waves of other polarizations, increasing specificity of the light passing through polarizer.

[0057] The ESFG light **136** is split using a synchronizer **140** to form a first portion of ESFG light **136a** and a second portion of ESFG light **136b**. The synchronizer **140** can form the first portion of ESFG light **136a** and the second portion of ESFG light **136** by oscillating at a frequency of about 400 Hz to about 600 Hz, e.g., about 400 Hz to about 450 Hz, about 450 Hz to about 500 Hz, about 500 Hz to about 550 Hz, or about 550 Hz to about 600 Hz. Additionally, the synchronizer **140** can form the first portion of ESFG light **136a** and the second portion of ESFG light **136** by rotating at a scan angle of about -1.5° to about 1.5° and oscillating at a frequency of about 500 Hz. In an aspect, the synchronizer **140** can produce a two-step phase-cycling system having two waveforms of (0,0) and (0, π). In an aspect, the synchronizer **140** can operate in a step-wise manner and/or continuously rotate over any suitable duration. Alternatively, the synchronizer **140** can produce a four-step phase-cycling system having four waveforms of (0,0), (0, $\pi/2$) and (0, π) and (0, $3\pi/2$). Without being bound by theory, by separating the signals of the two-step phase-cycling scheme vertically into two portions of light, e.g., a first portion of ESFG light **136a** and a second portion of ESFG light **136b**, a background-free 2D-ESFG signal can be collected.

[0058] The first portion of ESFG light **136a** and the second portion of ESFG light **136b** can then be detected using the detector **142**. In an aspect, the detector **142** can detect the first portion of ESFG light **136a** and the second portion of ESFG light **136b** by converting an incoming photon into an electron charge at the semiconductor-oxide interface of the capacitor, thereby providing an electron signal corresponding to the photons entering the detector. Without being bound by theory, detecting the first portion of the ESFG light **136a** and the second portion of ESFG light **136b**, a background correction can be performed, and subsequently a background-free spectra can be obtained.

[0059] The signal detected at the detector **142** can be the sum of the rephasing (R) and non-rephasing (NR) signals of the ESFG light **136** as the R and NR signals are in the same phase-matched directions and can be detected concurrently. Without wishing to be bound by theory, by detecting the R and NR signals concurrently, a background spectra can be obtained and a background correction can be performed. The NR and R signals can be isolated by employing the phase-cycling scheme of $\phi_{12}=0$ and $\phi_{12}=\pi/2$, according to the below equations:

$$S(\phi_{12}=0) \propto R^{(R)} + R^{(NR)} \quad \text{Eq. 1}$$

$$S(\phi_{12}=\pi/2) \propto -iR^{(R)} + iR^{(NR)} \quad \text{Eq. 2}$$

$$S(\phi_{12}=0) + iS(\phi_{12}=\pi/2) \propto R^{(R)} \quad \text{Eq. 3}$$

$$S(\phi_{12}=0) - iS(\phi_{12}=\pi/2) \propto R^{(NR)} \quad \text{Eq. 4}$$

[0060] Accordingly, performing the combinations and taking the Fourier transform along both τ and t_3 axes can give the 2D rephasing and non-rephasing spectra.

EXAMPLES

Example 1

[0061] Now referring to FIG. 2A, signal intensity data collected using the 2D-ESFG **100**, as described herein, is shown. The detected signals, as a function of τ in a partial rotating frame for $\phi_{12}=0$ and $\phi_{12}=\pi$ at the probe wavelength of 503 nm and T_w of 1 ps, where T_w is the time delay between the pump pair of light and the SWIR both showed the oscillatory features with the offsets. The $\phi_{12}=0$ minus $\phi_{12}=\pi$ showed the subtraction of the signals for $\phi_{12}=0$ and $\phi_{12}=\pi$. The phases of the oscillatory signal were opposite for $\phi_{12}=0$ and $\phi_{12}=\pi$, and the pump-probe background was unchanged. Accordingly, the two-step phase-cycling scheme can remove the pump-probe background and enhance the desired 2D signal, as shown in FIG. 2A.

[0062] A reflection geometry was used for the 2D-ESFG apparatus described herein. The reflection geometry can be represented as $S(\tau, T_w, \lambda_3; \phi_{12})$, where τ is the time delay between the pump pair of light, T_w is the time delay between the pump pair of light and the SWIR, and λ_3 is the wavelength of the 2D-ESFG, and ϕ_{12} is the relative carrier wave phase shift. A galvanometer mirror operating at 500 Hz collected the signals of $\phi_{12}=0$ and $\phi_{12}=\pi$ with the 2D-ESFG described herein for a 10 μM Ap3, SHG imaging solution including (E)-4-((4-(dihexylamino)phenyl)diazonyl)-1-(3-(triethylammonio) propyl)pyridin-1-ium bromide, at $T_w=1$ ps. The frequency domain can be described as $S(\tau, T_w, \lambda_3; \phi_{12}=0)$ and $S(\tau, T_w, \lambda_3; \phi_{12}=\pi)$. The background-free signal was obtained by the subtraction: $S(\tau, T_w, \lambda_3) = S(\tau, T_w, \lambda_3; \phi_{12}=0) - S(\tau, T_w, \lambda_3; \phi_{12}=\pi)$. Fourier transform uses data as a function of equally spaced frequency. Therefore, a Jacobian transformation and a subsequent interpolation along the frequency axis was performed to obtain $S(\tau, T_w, f_3)$ so that the Fourier transform could be a function of equally spaced frequency. The Fourier transform data along both τ and t_3 axes, was then used to determine the complex absorptive 2D-ESFG spectrum $S(v_1, T_w, v_3)$. The real part of $S(v_1, T_w, v_3)$ was absorptive, and shown in FIG. 2B. The imaginary part of (v_1, T_w, v_3) showed the dispersive spectrum (not shown).

Example 2

[0063] A rotating frame acquisition was performed to collect signal intensity data using the 2D-ESFG, described herein, as a function of coherence time t at 516 nm for $\Delta\phi=0-\Delta\phi=\pi$, and for n-type GaP (**100**) at $T_w=20$ ps. A spectrum with the scan of τ was obtained, as shown in FIG. 3. The emitted 2D-ESFG field had the feature of the interferences oscillating at optical frequencies, $E(t, \tau) \propto \exp(-i\omega\tau + i\phi_{12})$. The sampling steps in the time domain were small, e.g., less than 1 fs such as 0.87 fs at 520 nm, allowing for the acquisition of at least two samples during one optical cycle (subject to the Shannon-Nyquist criterion), the resolution of coherent oscillations, and the determination of frequencies.

[0064] Data collection occurred at about 100 data points to characterize the signal at a single time delay, T_w . These coherent oscillations were shifted to an arbitrary frequency or completely removed with the dispersive filter pulse shaper **130**. By keeping both carrier waves in phase while shifting the time-domain carrier-envelope phase ϕ_{CEP} of the second pulse with respect to the first pulse as a function of

the time delay τ , $\phi_{CEP}(\omega_0, \tau) = (1 - \gamma_0)\omega_0\tau$, where ω_0 is the center frequency of the pump spectrum, and γ_0 controls the carrier-envelope phase (CEP) evolution when $\gamma_0=1$, no CEP shift between two pulses occurred. Accordingly, the oscillations at the frequency of transition, which is denoted as the no rotating frame measurement occurred. Alternatively, when $\gamma_0=0$ the oscillations were shifted to the origin of the frequency space and oscillated with $\omega - \omega_0$, which is denoted as full rotating frame. Moreover, when $0 < \gamma_0 < 1$, the frequency of the oscillations were reduced and were denoted as partial rotating frame. Without wishing to be bound by theory the $0 < \gamma_0 < 1$, e.g., rotating frame, allowed for, the scan of T_w to be rapid, while maintaining data accuracy and the ability to obtain a background-free spectra.

Example 3

[0065] A partially rotating sampling scheme with $\gamma_0=0.3$, and 50 τ steps evenly between 0 and 60 fs was performed for In-type GaP (100) at $T_w=20$ ps using the $\Delta\phi=0$ and $\Delta\phi=\pi/2$ phase cycling scheme was performed, where a four-step phase-cycling scheme was performed a four-step phase-cycling scheme, $\phi_{12}=0, \pi/2, \pi, 3\pi/2$. Each measurement was performed over 5 minutes at one T_w . An additional subtraction was performed to obtain a background free signal of ($\phi_{12}=0$) and $S(\phi_{12}=\pi/2)$, according to the following equation:

$$S(\phi_{12} = 3\pi/2) \propto iR^{(R)} - iR^{(NR)} \propto -S(\phi_{12} = \pi/2) \quad \text{Eq. 5}$$

$$[S(\phi_{12} = 0) - S(\phi_{12} = \pi/2)] + \quad \text{Eq. 6}$$

$$[S(\phi_{12} = 0) - S(\phi_{12} = 3\pi/2)] \propto S(\phi_{12} = 0)$$

$$[S(\phi_{12} = \pi/2) - S(\phi_{12} = 0)] - \quad \text{Eq. 7}$$

$$[S(\phi_{12} = 3\pi/2) - S(\phi_{12} = 0)] \propto S(\phi_{12} = \pi/2)$$

[0066] Combinations and Fourier transformations along both τ and t_3 were performed to get the 2D rephasing and non-rephasing spectra. The signal $S(\phi_{12}=0)$ and $S(\phi_{12}=\pi)$ in this phase-cycling provided the 2D absorption spectrum. Rephasing spectra obtained from the four-step phase-cycling scheme are shown in FIGS. 4A-4C. Non-rephasing spectra obtained from the four-step phase-cycling scheme are shown in FIGS. 5A-5C. A sum of the rephasing spectra and non-rephasing spectra obtained from the four-step phase-cycling scheme are shown in FIGS. 6A-6C. Without being bound by theory, the four-step phase-cycling scheme allowed for a rapid analysis, background free spectra, to be collected.

ASPECTS LISTING

[0067] The present disclosure provides, among others, the following aspects, each of which can be considered as optionally including any alternate aspects:

[0068] Clause 1. A two-dimensional electronic sum frequency generation (2D-ESFG) apparatus, the apparatus comprising: an amplifier comprising a laser source; a broadband optical parametric amplifier (BOPA) optically coupled to the amplifier, the BOPA comprising a two-stage amplifier; an etalon optically coupled to the amplifier, the etalon comprising two or more partially reflective substrate optical flats; a non-

collinear optical parametric amplifier (NOPA) optically coupled to the amplifier; a dispersive filter pulse shaper optically coupled to the NOPA; a synchronizer comprising a galvanometer mirror optically coupled to the BOPA, the etalon, and the dispersive filter pulse shaper; and a detector optically coupled to the synchronizer.

[0069] Clause 2. The apparatus of clause 1, wherein the laser source comprises a titanium:sapphire laser.

[0070] Clause 3. The apparatus of any one of clauses 1 or 2, further comprising a first beam splitter and a second beam splitter.

[0071] Clause 4. The apparatus of clause 3, wherein the first beam splitter is optically coupled to the amplifier, the BOPA, and the second beam splitter.

[0072] Clause 5. The apparatus of clause 3, wherein the second beam splitter is optically coupled to the first beam splitter, the etalon, and the NOPA.

[0073] Clause 6. The apparatus of any one of clauses 1-5, wherein the galvanometer mirror comprises a single-axis galvanometer mirror.

[0074] Clause 7. The apparatus of any one of clauses 1-6, wherein the detector comprises a charge-coupled detector (CCD).

[0075] Clause 8. A two-dimensional electronic sum frequency generation (2D-ESFG) apparatus, the apparatus comprising: an amplifier comprising a laser source adapted to emit a laser light; a noncollinear optical parametric amplifier (NOPA) adapted to shape the laser light emitted from the amplifier; a dispersive filter pulse shaper adapted to generate a pulse pump pair from the laser light shaped by the NOPA; a synchronizer comprising a galvanometer mirror adapted to reflect the pulse pump pair; and a detector adapted to detect a wavelength of the pulse pump pair.

[0076] Clause 9. The apparatus of clause 8, wherein the laser source comprises a titanium:sapphire laser.

[0077] Clause 10. The apparatus of any one of clauses 8 or 9, further comprising a first beam splitter optically coupled to an amplifier.

[0078] Clause 11. The apparatus of clause 10, wherein the first beam splitter is further optically coupled to a second beam splitter.

[0079] Clause 12. The apparatus of clause 11, wherein the second beam splitter is further optically coupled to the NOPA.

[0080] Clause 13. The apparatus of any one of clauses 8-12, wherein the galvanometer mirror comprises a single-axis galvanometer mirror.

[0081] Clause 14. The apparatus of any one of clauses 8-14, wherein the detector comprises a charge-coupled detector (CCD).

[0082] Clause 15. A method, the method comprising: emitting a light from an amplifier to a first beam splitter, the first beam splitter configured to produce a first portion of light and a second portion of light; producing a third portion of light and a fourth portion of light by directing the second portion of light to a second beam splitter; directing the first portion of light to a broadband optical parametric amplifier (BOPA); directing the third portion of light to an etalon comprising two or more partially reflective substrate optical flats; directing the fourth portion of light to a noncollinear optical parametric amplifier (NOPA), wherein the fourth portion of light exits the NOPA and is

directed to a dispersive filter pulse shaper; producing an ESFG light by overlaying the first portion of light exiting the BOPA, the third portion of light exiting the etalon, and the fourth portion of light exiting the dispersive filter pulse shaper on a sample; splitting the ESFG light using a synchronizer to form a first portion of ESFG light and a second portion of ESFG light; and detecting the first portion of ESFG light and the second portion of ESFG light.

[0083] Clause 16. The method of clause 15, wherein the first portion of light comprises an ultra-broadband short wave infrared light (SWIR) comprising: a wavelength of about 1200 nm to about 2400 nm; pulse energy of about 200 μ J to about 300 μ J; and a pulse duration of about 100 fs to about 300 fs.

[0084] Clause 17. The method of any one of clauses 15 or 16, wherein the third portion of light comprises: a wavelength of about 700 nm to about 900 nm; a pulse energy of about 1.7 mJ to about 1.9 mJ; and a pulse duration of about 1 ps to about 1000 ps.

[0085] Clause 18. The method of any one of clauses 15-17, wherein the fourth portion of light comprises: a wavelength of about 500 nm to about 540 nm; and a pulse energy of about 5 μ J to about 10 μ J.

[0086] Clause 19. The method of any one of clauses 15-18, further comprising splitting the ESFG light by rotating the synchronizer at a scan angle of about -1.5° to about 1.5° .

[0087] Clause 20. The method of any one of clauses 15-19, further comprising splitting the ESFG light by oscillating the synchronizer at a frequency of about 400 Hz to about 600 Hz.

[0088] As is apparent from the foregoing general description and the specific aspects, while forms of the aspects have been illustrated and described, various modifications can be made without departing from the spirit and scope of the present disclosure. Accordingly, it is not intended that the present disclosure be limited thereby. Likewise, the term “comprising” is considered synonymous with the term “including.” Likewise whenever a composition, an element or a group of elements is preceded with the transitional phrase “comprising,” it is understood that we also contemplate the same composition or group of elements with transitional phrases “consisting essentially of,” “consisting of,” “selected from the group of consisting of,” or “is” preceding the recitation of the composition, element, or elements and vice versa, for example, the terms “comprising,” “consisting essentially of,” “consisting of” also include the product of the combinations of elements listed after the term.

[0089] The use of headings is for purposes of convenience only and does not limit the scope of the present disclosure.

[0090] For purposes of this present disclosure, and unless otherwise specified, all numerical values within the detailed description and the claims herein are modified by “about” or “approximately” the indicated value, and consider experimental error and variations that would be expected by a person having ordinary skill in the art. For the sake of brevity, only certain ranges are explicitly disclosed herein. However, ranges from any lower limit may be combined with any upper limit to recite a range not explicitly recited, as well as, ranges from any lower limit may be combined with any other lower limit to recite a range not explicitly recited, in the same way, ranges from any upper limit may

be combined with any other upper limit to recite a range not explicitly recited. Additionally, within a range includes every point or individual value between its end points even though not explicitly recited. Thus, every point or individual value may serve as its own lower or upper limit combined with any other point or individual value or any other lower or upper limit, to recite a range not explicitly recited.

[0091] As used herein, the term “about” when referring to a measurable value such as an amount, a temporal duration, and the like, is meant to encompass variations of $\pm 20\%$, $\pm 15\%$, $\pm 10\%$, $\pm 5\%$, $\pm 1\%$, or $\pm 0.1\%$ from the specified value, as such variations are appropriate.

[0092] As used herein, the indefinite article “a” or “an” shall mean “at least one” unless specified to the contrary or the context clearly indicates otherwise. For example, aspects comprising “a metal” include aspects comprising one, two, or more metals, unless specified to the contrary or the context clearly indicates only one metal is included.

[0093] While the foregoing is directed to aspects of the present disclosure, other and further aspects of the disclosure may be devised without departing from the basic scope thereof, and the scope thereof is determined by the claims that follow.

What is claimed is:

1. A two-dimensional electronic sum frequency generation (2D-ESFG) apparatus, the apparatus comprising:

- an amplifier comprising a laser source;
- a broadband optical parametric amplifier (BOPA) optically coupled to the amplifier, the BOPA comprising a two-stage amplifier;
- an etalon optically coupled to the amplifier, the etalon comprising two or more partially reflective substrate optical flats;
- a noncollinear optical parametric amplifier (NOPA) optically coupled to the amplifier;
- a dispersive filter pulse shaper optically coupled to the NOPA;
- a synchronizer comprising a galvanometer mirror optically coupled to the BOPA, the etalon, and the dispersive filter pulse shaper; and
- a detector optically coupled to the synchronizer.

2. The apparatus of claim 1, wherein the laser source comprises a titanium:sapphire laser.

3. The apparatus of claim 1, further comprising a first beam splitter and a second beam splitter.

4. The apparatus of claim 3, wherein the first beam splitter is optically coupled to the amplifier, the BOPA, and the second beam splitter.

5. The apparatus of claim 3, wherein the second beam splitter is optically coupled to the first beam splitter, the etalon, and the NOPA.

6. The apparatus of claim 1, wherein the galvanometer mirror comprises a single-axis galvanometer mirror.

7. The apparatus of claim 1, wherein the detector comprises a charge-coupled detector (CCD).

8. A two-dimensional electronic sum frequency generation (2D-ESFG) apparatus, the apparatus comprising:

- an amplifier comprising a laser source adapted to emit a laser light;
- a noncollinear optical parametric amplifier (NOPA) adapted to shape the laser light emitted from the amplifier;
- a dispersive filter pulse shaper adapted to generate a pulse pump pair from the laser light shaped by the NOPA;

a synchronizer comprising a galvanometer mirror adapted to reflect the pulse pump pair; and
 a detector adapted to detect a wavelength of the pulse pump pair.

9. The apparatus of claim 8, wherein the laser source comprises a titanium:sapphire laser.

10. The apparatus of claim 8, further comprising a first beam splitter optically coupled to an amplifier.

11. The apparatus of claim 10, wherein the first beam splitter is further optically coupled to a second beam splitter.

12. The apparatus of claim 11, wherein the second beam splitter is further optically coupled to the NOPA.

13. The apparatus of claim 8, wherein the galvanometer mirror comprises a single-axis galvanometer mirror.

14. The apparatus of claim 8, wherein the detector comprises a charge-coupled detector (CCD).

15. A method, the method comprising:
 emitting a light from an amplifier to a first beam splitter, the first beam splitter configured to produce a first portion of light and a second portion of light;
 producing a third portion of light and a fourth portion of light by directing the second portion of light to a second beam splitter;
 directing the first portion of light to a broadband optical parametric amplifier (BOPA);
 directing the third portion of light to an etalon comprising two or more partially reflective substrate optical flats;
 directing the fourth portion of light to a noncollinear optical parametric amplifier (NOPA), wherein the fourth portion of light exits the NOPA and is directed to a dispersive filter pulse shaper;

producing an ESFG light by overlaying the first portion of light exiting the BOPA, the third portion of light exiting the etalon, and the fourth portion of light exiting the dispersive filter pulse shaper on a sample;
 splitting the ESFG light using a synchronizer to form a first portion of ESFG light and a second portion of ESFG light; and
 detecting the first portion of ESFG light and the second portion of ESFG light.

16. The method of claim 15, wherein the first portion of light comprises an ultra-broadband short wave infrared light (SWIR) comprising:
 a wavelength of about 1200 nm to about 2400 nm;
 pulse energy of about 200 μ J to about 300 μ J; and
 a pulse duration of about 100 fs to about 300 fs.

17. The method of claim 15, wherein the third portion of light comprises:
 a wavelength of about 700 nm to about 900 nm;
 a pulse energy of about 1.7 mJ to about 1.9 mJ; and
 a pulse duration of about 1 ps to about 1000 ps.

18. The method of claim 15, wherein the fourth portion of light comprises:
 a wavelength of about 500 nm to about 540 nm; and
 a pulse energy of about 5 μ J to about 10 μ J.

19. The method of claim 15, further comprising splitting the ESFG light by rotating the synchronizer at a scan angle of about -1.5° to about 1.5° .

20. The method of claim 15, further comprising splitting the ESFG light by oscillating the synchronizer at a frequency of about 400 Hz to about 600 Hz.

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